

United States Patent and Trademark Office

UNITED STATES DEPARTMENT OF COMMERCE
United States Patent and Trademark Office
Address: COMMISSIONER FOR PATENTS
P.O. Box 1450
Alexandria, Virginia 22313-1450
www.uspto.gov

FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/27/2001	David D. Crouch	PD-00W158	2929
10/03/2003	BEST AVALLA	EXAM	INER
KET ADMINISTRATIO	ON	WIMER, MICHAEL C	
STEMS COMPANY 1/E150)		ART UNIT	PAPER NUMBER
150		2821	
	09/27/2001 10/03/2003 KET ADMINISTRATION STEMS COMPANY 1/E150)	09/27/2001 David D. Crouch 10/03/2003 BEST AVAILA KET ADMINISTRATION STEMS COMPANY 1/E150) 150	David D. Crouch PD-00W158 BEST AVAILAL EXAM WIMER, M STEMS COMPANY 1/E150) 150 David D. Crouch PD-00W158 EXAM WIMER, M ART UNIT 2821

DATE MAILED: 10/03/2003

Please find below and/or attached an Office communication concerning this application or proceeding.

<u> </u>		<u> </u>		
	Application No.	Applicant(s)		
Office Action Summers	09/965,206	CROUCH ET AL.		
Office Action Summary	Examin r	Art Unit		
The SAAU DIO DATE ALL'	Michael C. Wimer	2821		
The MAILING DATE of this communication app Period for Reply	ears on the cover sn	eet with the correspondence address		
A SHORTENED STATUTORY PERIOD FOR REPL' THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.1 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a repl If NO period for reply is specified above, the maximum statutory period v - Failure to reply within the set or extended period for reply will, by statute - Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b). Status	36(a). In no event, however, y within the statutory minimur will apply and will expire SIX (a, cause the application to bec	may a repry be times filed may a repry be time and thirty (30) days will be considered the by: (6) MONTHS from the mailing date of this communication. come ABANDONED (35 U.S.C. § 133).		
1) Responsive to communication(s) filed on 09 s	September 2003 .			
2a) ☐ This action is FINAL . 2b) ☑ Th	is action is non-final			
3) Since this application is in condition for allowationsed in accordance with the practice under				
Disposition of Claims	•			
4)⊠ Claim(s) <u>1-31 and 34-37</u> is/are pending in the application.				
4a) Of the above claim(s) is/are withdraw	wn from consideratio	on.		
5)⊠ Claim(s) <u>10-18 and 25-29</u> is/are allowed.				
6)⊠ Claim(s) <u>1-9,19-24 and 30-37</u> is/are rejected.				
7) Claim(s) is/are objected to.				
8) Claim(s) are subject to restriction and/o	r election requireme	nt.		
Application Papers				
9) The specification is objected to by the Examine		la butha Francisca		
10) The drawing(s) filed on is/are: a) acce Applicant may not request that any objection to th	•	•		
11) The proposed drawing correction filed on		• • • • • • • • • • • • • • • • • • • •		
If approved, corrected drawings are required in re				
12) The oath or declaration is objected to by the Ex	-			
Priority under 35 U.S.C. §§ 119 and 120				
13) Acknowledgment is made of a claim for foreign	n priority under 35 U	.S.C. § 119(a)-(d) or (f).		
a) ☐ All b) ☐ Some * c) ☐ None of:		(4)		
1.☐ Certified copies of the priority document	s have been receive	d.		
2. Certified copies of the priority documents have been received in Application No				
3. Copies of the certified copies of the prio application from the International Bu	rity documents have reau (PCT Rule 17.2	been received in this National Stage 2(a)).		
* See the attached detailed Office action for a list	•			
14) Acknowledgment is made of a claim for domesti	•			
 a) The translation of the foreign language pro 15)	• •			
Attachment(s)				
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449) Paper No(s)	5) 🔲 No	erview Summary (PTO-413) Paper No(s) tice of Informal Patent Application (PTO-152) ner:		

Art Unit: 2821

BEST AVAILABLE

DETAILED ACTION

Claim Rejections - 35 USC § 103

- 1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claims 1-5,9,19,23,24,30 and 34-37 are rejected under 35 U.S.C. 103(a) as being unpatentable over Kanamaluru et al (6370398 B1).

Regarding Claims 1-5,9,19,23,24,30 and 34-37 Kanamaluru et al show in Figures 4 and 5, a wavefront transformer/method of making thereof, 64,65 which transforms the EM wavefront having a given shape to a reflected wavefront having a different shape comprising a substrate 64, with an arbitrarily-shaped and a substantially flat conductive surface for reflecting incident EM energy, and a plurality of openings 65 in the conductive surface, each opening formed by a respective one of a plurality of discrete cavities extending from the conductive surface, each cavity having a bottom surface, each cavity having a selected position on the conductive surface with respect to a focal point to induce a propagation phase shift over the distance to the focal point (Fig. 5), each cavity inducing a local phase shift in the reflected EM energy as a function of a selected dimension of the cavity, and the combined propagation phase shift and local phase shift from the plurality of cavities places the reflected EM energy in phase at the focal point. It would have been obvious to the skilled artisan that the

phase shift claimed here results due to the quarter wavelength depth of the cavities in the metal twist plate 64.

Further regarding Claim 4, column 5, fourth paragraph suggests two plates.

Further regarding Claim 19, Kanamaluru et al. teaches that the plate 64 may be integrated with the electronics (col. 6, lines 58-65).

3. Claims 1,6-8,20-22 and 31 are rejected under 35 U.S.C. 103(a) as being unpatentable over Bains et al (6429823 B1).

Regarding Claims 1,6-8,20-22 and 31, Bains et al teach and show a wavefront transformer 204 formed of a substrate of adjustable horn cavities 202, where their depth are adjustable via short 216 and are spaced according to a particular design, and where the phase within the conductive substrate collectively formed by the horns varies to provide a propagation phase shift. It would have been obvious to the skilled artisan that the combined propagation phase shift and local phase shift from the plurality of cavities places the EM energy in phase at the focal point (at 202) of the reflector. The cavities are circular, cylindrical and form an equilateral-triangular arrangement as shown in Fig. 2.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Michael C. Wimer whose telephone number is (703) 305-3555. The examiner can normally be reached on M-F.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Don K. Wong can be reached on (703) 308-4856. The fax phone number for the organization where this application or proceeding is assigned is (703) 872-9306.

Application Control Name Coloss, 206

Art Unit: 2821

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0956.

Michael C. Wimer Primary Examiner

Art Unit 2821

MCW 22 September 2003